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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/519,016	12/21/2004	Richard Schmidt	52201-0631	3200
28481 TIAJOLOFF &	7590 04/06/201 KELLY	EXAMINER		
	UILDING, 37TH FLO	DEHGHAN, QUEENIE S		
405 LEXINGTON AVENUE NEW YORK, NY 10174			ART UNIT	PAPER NUMBER
			1791	
			MAIL DATE	DELIVERY MODE
			04/06/2010	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

	Application No.	Applicant(s)
	10/519,016	SCHMIDT ET AL.
Office Action Summary	Examiner	Art Unit
	QUEENIE DEHGHAN	1791
The MAILING DATE of this communication appeariod for Reply	ppears on the cover sheet with th	e correspondence address
A SHORTENED STATUTORY PERIOD FOR REP WHICHEVER IS LONGER, FROM THE MAILING - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory perio - Failure to reply within the set or extended period for reply will, by statu. Any reply received by the Office later than three months after the mail earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICATI 1.136(a). In no event, however, may a reply be d will apply and will expire SIX (6) MONTHS for the, cause the application to become ABANDO	ON. e timely filed rom the mailing date of this communication. DNED (35 U.S.C. § 133).
Status		
Responsive to communication(s) filed on 20 This action is FINAL . 2b) ☑ Th Since this application is in condition for allow closed in accordance with the practice under	is action is non-final. ance except for formal matters,	
Disposition of Claims		
4) Claim(s) 3-8 and 22-36 is/are pending in the 4a) Of the above claim(s) is/are withdr 5) Claim(s) is/are allowed. 6) Claim(s) 3-8, 22-36 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and	rawn from consideration.	
Application Papers		
9) The specification is objected to by the Examir 10) The drawing(s) filed on is/are: a) according a deplicant may not request that any objection to the Replacement drawing sheet(s) including the correct of the second state of the second sec	ccepted or b) objected to by the drawing(s) be held in abeyance. Section is required if the drawing(s) is	See 37 CFR 1.85(a). objected to. See 37 CFR 1.121(d).
Priority under 35 U.S.C. § 119		
a) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority document application from the International Bure * See the attached detailed Office action for a list	nts have been received. nts have been received in Applic iority documents have been rece au (PCT Rule 17.2(a)).	cation No vived in this National Stage
Attachment(s) 1) ☑ Notice of References Cited (PTO-892)	4)	ary (PTO-413)
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date	Paper No(s)/Mai	

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DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- 3. Claims 8, 22-27, and 33-36 are rejected under 35 U.S.C. 103(a) as being unpatentable over Rau et al. (4,162,908) in view of Ruppert et al. (5,788,730) and Meyer (4,990,740) or Kamp et al. (4,992,642). Regarding claims 23-27 and 35-36, Rau et al. disclose a method for glass preform using a plasma burner, the method comprising supplying a hydrogen-free media flow comprising SiCl₄ and oxygen to a multi-nozzle deposition burner and focusing the media flow into a plasma zone via a media nozzle, wherein the SiCl₄ is oxidized to form SiO₂ particles and depositing the

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SiO₂ particles on a surface while being vitrified (col. 1 line 64 to col. 2 line 22, line 59, col. 4 lines 24-27, figures 1 and 2). Rau et al. disclose a multi-nozzle burner, but fail to disclose a media nozzle of that tapers in the direction of the plasma zone. Ruppert teaches a multi-nozzle burner for deposition of glass starting materials on a surface, wherein one of the nozzles has a wall defining a passage that tapers in a tapered portion towards the direction of the plasma zone and communicating with a nozzle opening. Although the burner nozzle is employed for a flame hydrolysis process, Ruppert teaches the tapered nozzle has the effect of focusing a gas stream toward the area of the reaction zone, stabilizing the gas stream, and preventing reaction in the nozzle opening (col. 3 lines 50-67, figure). Although the tapered nozzle is applied to a barrier gas stream, it would have been obvious to one of ordinary skill in the art at the time of the invention to have similarly adapted a tapered passage to the media nozzle of Rau, such that the media flow passes through the passage and through the nozzle opening, since it allows for the stabilization and focus of the media flow towards the plasma reaction zone and more efficient deposition of the SiO₂ particles.

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4. Ruppert does not specify the length of the tapered portion of the nozzle or the nozzle opening size. However, tapered nozzles and nozzle openings of various sizes are well known in the art, such as the tapered nozzle of Meyer or the tapered nozzle of Kamp. Meyer teaches a multi-nozzle burner wherein a media is directed towards a plasma zone through a passage and nozzle opening, the passage being tapered in the direction of the plasma zone and having a tapered portion length of at least 8mm (col. 7 lines 44-47, 50-51, figure 1). Kamp teaches a multi-nozzle burner wherein the nozzle

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has a nozzle opening of 5mm in diameter (figure 2, col. 4 lines 14-15). The length of the tapered portion is not specifically disclosed. However, as shown proportionally in figure 2, with a nozzle opening of 5mm, the tapered portion is at least 5mm. Although the nozzles of Meyer and Kamp are utilized for a different purpose, selecting the length of a tapered nozzle, for instance greater than 8mm and a nozzle opening (i.e. 5mm) would be choices that are well known in the art. Accordingly, it would have been obvious to one of ordinary skill in the art at the time of the invention to have reasonably expected the nozzle of Rau and Ruppert to have a tapered portion with a desired length of at least 8mm and an opening of about 5mm, for instance, as such length and size are known in the art while still providing the desired flow characteristics to the media delivered through the nozzle.

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- 5. Regarding claims 8 and 33, Rau discloses a glass starting material that contains a fluorine-containing component (col. 2 lines 56-29).
- 6. Regarding claims 22 and 34, Rau teaches the multi-nozzle burner includes a plurality of additional nozzles (items 11 and 12) with cylindrical walls concentric with and surround the media nozzle and defining annular gaps between each other and the media nozzle (fig. 1 & 2, column 3 lines 56-59).
- 7. Claims 3-6 and 28-31 are rejected under 35 U.S.C. 103(a) as being unpatentable over Rau et al. in view of Ruppert et al. (5,788,730), and Meyer (4,990,740) or Kamp et al. (4,992,642), as applied to claim 1, in further view of Edahiro et al. (4,402,720). Regarding claims 3-4 and 28-29, Rau teaches media flow that is enveloped with oxygen working gas since it already well mixed in with the media flow (col. 3 lines 15-25, 53-64.

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Rau also teaches flowing oxygen from a first gas nozzle of the deposition burner (col. 3 lines 15-25). Although the oxygen from the first gas nozzle does envelope the media flow, Rau also mentions the working gas has been supplied through the media nozzle. Edahiro teaches a plasma burner comprising of multiple nozzles, wherein a glass starting material flows from a media nozzle and an oxygen-containing working gas flows from a first working gas nozzle such that the oxygen envelops the media flow. Also supplying the working gas separate to allow for the formation of Si-N bonds first before Si-O bonds in the case of depositing nitrogen doped silica particles (col. 6 lines 31-65, fig 3a). Although not specifically disclosed, it would be reasonable to expect that the first working gas nozzle of Edahiro functions as a diffuser since it disperse the oxygen containing working gas such that the glass starting material and working gas are combined to form the glass particles (col. 9 lines 40-44). Additionally, Ruppert teaches the first tube surrounding a tapered nozzle results in an expansion area, also known as the diffuser area, which allows for a flow of gas in turbulent manner (col. 6, lines 13-25). It would have been obvious to one of ordinary skill in the art at the time of the invention to have adapted a first working gas nozzle for distributing a oxygen-containing working gas that envelops the glass starting material from the media nozzle in the process of Rau because supplying oxygen working gas from a separate nozzle allows for the desired incorporation of dopants such as nitrogen in the silica glass, as taught by Edahiro. Also, it would have been obvious to one of ordinary skill in the art at the time of the invention to have also flowed the working gas in a turbulent manner from a nozzle

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that functions as a diffuser in order to ensure the oxidation reaction of the glass starting material, by the ample diffusion of the working gas into the glass starting material.

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- 8. Regarding claims 5 and 30, Rau teaches the working gas flow is enveloped by at least one oxygen-containing separating gas flow exiting from an annular gap nozzle coaxially surrounding the working gas nozzle when exiting from the working gas nozzle (col. 3 lines 15-25, 60-64, col. 4 lines 11-15, figures 1 and 2).
- 9. Regarding claims 6 an 31, Rau discloses producing a plasma zone by a high-frequency excitation inside a burner tube (12) into which a mixture of media flow and working gas flow is introduced (col. 3 lines 15-25, 60-62).
- 10. Claims 7 and 32 are rejected under 35 U.S.C. 103(a) as being unpatentable over Rau et al. (4,162,908) in view of Ruppert et al. (5,788,730) and Meyer (4,990,740) or Kamp et al. (4,992,642), as applied to claim 1 above, in view of Gouskov et al. (6,535,240). Rau et al. disclose supplying a glass starting material such as SiCl₄, but uses oxygen as a carrier gas. Gouskov et al. teaches a plasma vapor deposition process using a glass starting material, such as SiCl₄ also, and a carrier gas, wherein the carrier gas can alternatively be oxygen or nitrogen (col. 6 lines 25-46). It would have been obvious to one of ordinary skill in the art at the time of the invention to have utilized nitrogen gas as a carrier gas for the glass starting material as an alternative carrier gas in the process of Rau because Gouskov has demonstrated that it is known in the art and it predictable achieves the result of successfully serving to deliver the glass starting material as oxygen does.

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Response to Arguments

1. The drawing requirement has been withdrawn.

2. The previous office action indicated the allowable subject matter of claims 24-27. In view of a further search, it appears this is incorrect. The Examiner apologized for this error. A new non-final office action has been presented.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to QUEENIE DEHGHAN whose telephone number is (571)272-8209. The examiner can normally be reached on Monday through Friday 9:00am - 5:30pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Steven Griffin can be reached on 571-272-1189. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Queenie Dehghan/

Examiner, Art Unit 1791